(Following Paper ID and Roll No. to be filled in your Answer Book)

**PAPER ID: 2483** 

Roll No.

## B. Tech.

## (SEM. VI) THEORY EXAMINATION 2011-12

## ADVANCE SEMICONDUCTOR DEVICES

Time: 2 Hours

Total Marks: 50

Note: (1) Attempt all questions.

- (2) Marks are indicated for each question.
- (3) Assume the missing data, if any.
- (4) Useful Physical constants:

Boltzmann's constant,  $K = 1.38 \times 10^{-23} \text{ J/K}$ 

Electronic rest mass,  $m_0 = 9.11 \times 10^{-31} \text{ Kg}$ 

Planck's constant,  $h = 6.63 \times 10^{-34} \text{ J-s}$ 

Electronic charge,  $q = 1.60 \times 10^{-19} \,\mathrm{C}$ 

Permittivity of free space,  $\epsilon_0 = 8.85 \times 10^{-12} \text{ F/m}$ 

Electron effective mass,  $m_n^* = (1.1 \text{ m}_o)_{Si}$ ,  $(0.067 \text{ m}_o)_{GaAs}$ 

Hole effective mass,  $m_p^* = (0.56 \text{ m}_o)_{Si}$ ,  $(0.48 \text{ m}_o)_{GaAs}$ 

- 1. Attempt any *two* parts of the following: (2×6)
  - (a) (i) What do you mean by effective mass of carrier?
    What is the kinetic energy of a hole at the top of the valence band?
    - (ii) Calculate the relaxation times for electrons and holes in Si.
  - (b) Define and derive the expression for minority carrier life time.

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(c) A photon of monochromatic light of wavelength 5000 Å is absorbed in GaAs and excites an electron from the valence band into conduction band. Calculate the velocity of electron.

2. Attempt any *two* parts of the following:  $(2\times6=12)$ 

(a) Show that the depletion region capacitance of a p-n junction for any arbitrary doping on the two sides can always be expressed by

$$C_i = \epsilon_s A/W$$

where,  $\in$  s is the permittivity of the semiconductor,

A and W are the cross sectional area and depletion width of the junction.

- (b) A Si sample with doping concentration of  $10^{17}$  phosphorus atoms/cm³ is optically excited at 300 K such that  $g_{op} = 10^{20}$  EHP/cm³-sec and  $\tau_n = \tau_p = 10$  µsec. What is the separation of the quasi-Fermi levels? Draw the energy band diagram of the sample.
- (c) Assume that an ideal Schottky barrier is formed on n-type Si having 10<sup>16</sup> As atoms/cm<sup>3</sup>. The metal work function is 4.5 eV and Si electron affinity is 4 eV.
  - (i) Draw the equilibrium diagram and describe the contact.
  - (ii) Draw the forward and reverse biased diagram and explain.
- 3. Attempt any *two* parts of the following:  $(2\times6=12)$ 
  - (a) With a suitable diagram describe the working principle of a photodiode. Explain how the various quadrants of its V-I characteristics are used in different applications?
  - (b) Explain degenerate semiconductors. What are their

- different types? How do they differ from conventional semiconductor? What are the uses of these materials? Explain the device operation with characteristics.
- (c) What is meant by IMPATT? Describe briefly the principle of operation of IMPATT diode.
- 4. Attempt any *two* parts of the following:  $(2\times7=14)$ 
  - (a) Discuss briefly the principle of operation of a GaAs MESFET. Also derive an expression for I-V characteristic of the device. Enumerate special features of MESFETs.
  - (b) Sketch approximate distribution of charge, electric field and electrostatic potential in the ideal MOS diode using n-type Si in inversion condition and explain them.
  - (c) Describe briefly the principle of operation of charge coupled devices. With suitable schematics show the input and output arrangements for a CCD and explain charge transfer efficiency of the device.

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